PHOTOSENSITIVE COMPOSITION

Patent number:

JP2096755

Publication date:

1990-04-09

Inventor:

NAKAI HIDEYUKI; GOTO SEI; TOMIYASU HIROSHI;

KOBAYASHI YOSHIKO

Applicant:

KONISHIROKU PHOTO IND;; MITSUBISHI CHEM IND

Classification:

- international:

G03F7/004; G03F7/023

- european:

Application number: JP19880249398 19881003 Priority number(s): JP19880249398 19881003

Abstract of JP2096755

PURPOSE:To obtain a photosensitive compsn. having superior capacity for forming visible picture by exposure, as well as superior under developability and high sensitivity by constituting the compsn. of 1,2-naphthoquinone-2-diazide-4- sulfonic ester compd. an alkali soluble resin, a halomethyl oxadiazole compd., as a discoloring agent. CONSTITUTION:The title compsn. contains 1,2-naphthoquinone-2-diazide-4-sulfonic ester compd., the alkali-soluble resin, the halomethyl oxadiazole compd. which generates free halogen radicals by irradiating with active light rays, and a discoloring agent which changes its tone by the interaction with a photolysis of the halomethyl oxadiazole compd. Suitable alkali-soluble resin is particularly novolak resin and vinyl polymer having structure units having phenolic OH groups in the molecule. A photosensitive planographic printing plate having superior capacity for forming visible picture by exposure, superior under developability, as well as high sensitivity, is obtd. from the above-described compsn.

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> ₽Title: JP02096755A2: PHOTOSENSITIVE COMPOSITION

Propert Title: Photosensitive compsn. for lithographic plates - contg. 1,2-

naphthoguinone-2-diazo-4-sulphonic acid, alkali-soluble resin, dye, and

halo-methyl oxadiazole [Derwent Record]

JP Japan **P**Country:

> ₽Kind: Α

§Inventor: **NAKAI HIDEYUKI**;

GOTO SEI:

TOMIYASU HIROSHI: KOBAYASHI YOSHIKO:

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1990-04-09 / 1988-10-03 Published / Filed:

₽ Application

JP1988000249398

Number:

G03F 7/023; G03F 7/004; PIPC Code:

Priority Number: 1988-10-03 JP1988000249398

> PURPOSE: To obtain a photosensitive compsn. having superior **PAbstract**:

> > capacity for forming visible picture by exposure, as well as superior under developability and high sensitivity by constituting the compsn. of 1,2-naphthoquinone-2-diazide-4- sulfonic ester compd. an alkali soluble resin, a halomethyl oxadiazole compd., as a discoloring

agent.

CONSTITUTION: The title compsn. contains 1,2naphthoguinone-2-diazide-4-sulfonic ester compd., the alkalisoluble resin, the halomethyl oxadiazole compd. which generates free halogen radicals by irradiating with active light rays, and a discoloring agent which changes its tone by the interaction with a photolysis of the halomethyl oxadiazole compd. Suitable alkalisoluble resin is particularly novolak resin and vinyl polymer having structure units having phenolic OH groups in the molecule. A photosensitive planographic printing plate having superior capacity

for forming visible picture by exposure, superior under developability, as well as high sensitivity, is obtd. from the above-

described compsn.

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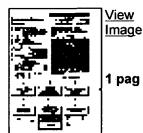
VINPADOC Legal Status: None Get Now: Family Legal Status Report

₱ Designated

DE FR GB

Country:

ষ্ট Family: **Publication** Pub. Date Filed Title



%	<u>US5219700</u>	1993-06-15	1992-03-24	Photosensitive composition containing 1,2- naphthoquinone-2-diazido-4-sulfonic acid ester, alkali-soluble resin, halomethyloxadiazole compound and a dye	
Ø	JP02096759A2	1990-04-09	1988-10-04	PHOTOSENSITIVE PLANOGRAPHIC PRINTING PLATE	
Ø	JP02096755A2	1990-04-09	1988-10-03	PHOTOSENSITIVE COMPOSITION	
E	EP0362778B1	1999-01-13	1989-10-02	Photosensitive composition	
X	EP0362778A3	1991-06-12	1989-10-02	Photosensitive composition	
医	EP0362778A2	1990-04-11	1989-10-02	Photosensitive composition	
Ø	DE68928903C0	1999-02-25	1989-10-02	LICHTEMPFINDLICHE ZUSAMMENSETZUNG	
Ø	CA2000111AA	1990-04-03	1989-10-03	PHOTOSENSITIVE COMPOSITION	
8	8 family members shown above				

POther Abstract Info:

DERABS C90-133305









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